

Electronic Acknowledgement Receipt

EFS ID:	1390038
Application Number:	10809011
International Application Number:	
Confirmation Number:	7829
Title of Invention:	Manufacturing method for a semiconductor device with reduced local current
First Named Inventor/Applicant Name:	Eiji Nishibe
Customer Number:	26211
Filer:	Samuel Borodach/Frances Eng-Moy
Filer Authorized By:	Samuel Borodach
Attorney Docket Number:	10417-103002
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Application Type:	Utility

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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1		10417103002Amendment.pdf	200600	yes	6

Multipart Description/PDF files in .zip description			
Document Description	Start	End	
Amendment After Final	1	1	
Claims	2	4	
Applicant Arguments/Remarks Made in an Amendment	5	6	

Warnings:

Information:

Total Files Size (in bytes):	200600
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New Applications Under 35 U.S.C. 111
If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371
If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.